IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patentee: Li-Te S. Lin, et al.

Patent No.: 6,849,531

Issue Date: February 1, 2005

Entitled: Phosphoric Acid Free Process for Polysilicon Gate Definition

Docket No.: 24061.506

Serial No.: 10/718,876

Filing Date: November 21, 2003

Mail Stop PGPUB Commissioner for Patents PO Box 1450 Alexandria, VA 22313-1450

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Dear Sir:

Patentee hereby requests refund of the pre-grant publication fee timely paid on November 30, 2004. A copy of Issue Fee Transmittal, indicating payment of publication fee and return postcard is enclosed herewith.

According to the Official Filing Receipt (copy enclosed) the pre-grant publication was scheduled to publish on May 26, 2005. Patentee notes that the subject application proceeded to allowance and issued prior to the projected publication date. It has been more than four weeks since the issue date and therefore, refund of the publication fee under 37 CFR 1.18(d) is respectfully requested.

Patentee respectfully requests that a refund of \$300.00 be credited to the Deposit Account of Haynes and Boone, LLP Number 08-1394. **This form submitted in duplicate.**

Date: 10-30-06

HAYNES AND BOONE, LLP 901 Main Street, Suite 3100 Dallas, Texas 75202-3789 Telephone: 972-739-8635

Facsimile: 214-200-0853

Respectfully submitted,

David M. O'Dell Registration No. 42,044

CERTIFICATE OF TRANSMISSION

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TAINES & D	OOKE EE.	DEC 2 1 2004	
APPLICANT	Lin et al.	HAYNES and BOONE, LLP	MARK OFF
SERIAL NO.	10/718876	RICHARDSON DATE FILED	11/21/2003
ATTORNEY DOCKET NO.	24061.506		
TITLE	Phosphoric Acid Free Process for Polysilicon Gate Definition		
SENDER'S INITIALS	DMO/lah/beb	DATE MAILED	11-30-04

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OC000000011940526

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Applicant(s)

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Assignment For Published Patent Application

Taiwan Semiconductor Manufacturing Co.;

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Foreign Applications

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Early Publication Request: No

Title

Phosphoric acid free process for polysilicon gate definition

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